


# Anisotropic Thermoelectric Power Factor of Two-Dimensional Materials with Periodic Potential Barriers: The Wigner-Rode Formalism

Adithya Kommini<sup>1</sup> and Zlatan Aksamija<sup>1\*</sup>

*University of Massachusetts Amherst, Amherst, Massachusetts 01003, USA*

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Thermoelectric (TE) devices enable robust solid-state conversion of waste heat to electricity, but their wide-spread adoption is still limited by relatively modest efficiency. A widely used approach to improve efficiency is to enhance the power factor through confinement of carriers or energy filtering by potential barriers. However, their relative influence and the resulting improvement in the power factor in two-dimensional (2D) materials is not well understood. Here we study single-layer 2D MoS<sub>2</sub> with lateral potential barriers to introduce either energy filtering or carrier confinement by changing the direction of the electric field, with confinement resulting when the electric field is parallel and energy filtering when the electric field is perpendicular to the potential barriers. We implement a Wigner-Rode model with electronic structure calculated from first principles to simulate the effect of the shape and size of potential barriers on parallel and perpendicular transport. Our results show that the power factor can be doubled, from 25 mWm<sup>-1</sup> K<sup>-2</sup> without barriers to over 50 mWm<sup>-1</sup> K<sup>-2</sup> for parallel transport in sharp, narrow potential wells. Perpendicular transport in smooth barriers results in a higher power factor compared to sharp barriers, while sharp barriers perform better in the case of transport parallel to the barriers, especially at small barrier widths. Our results aid in improving TE power factors and further the development of efficient waste-heat scavenging, flexible 2D TE converters, and Peltier cooling of nanoelectronics.

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## I. INTRODUCTION

Direct conversion from waste heat to electricity can be accomplished with thermoelectric (TE) converters based on the Seebeck effect [1]. Conversely, TE modules can employ the Peltier effect for localized cooling and thermal management [2]. These two ubiquitous applications, coupled with their robustness and scalability, have made TE converters attractive. Despite years of research, their efficiency remains modest. Efficient TE devices require materials with a high figure of merit ( $ZT$ ), i.e., a dimensionless metric that can assess the material's TE capability. The  $ZT$  is proportional to the power factor  $S^2\sigma T/\kappa$ , where  $\sigma$  is electrical conductivity and  $S$  is the Seebeck coefficient. Improving the power factor of a material helps to enhance  $ZT$ , but it requires that we increase  $S$  and  $\sigma$  simultaneously. This has long proven to be a challenge due to the interdependence between conductivity and the Seebeck coefficient. Multiple band-engineering [3–5] and reduced-dimensionality [6,7] approaches have been proposed to decouple this dependence and thereby enhance the power factor, but further research may be needed to realize it in practice.

Confinement reduces the dimensionality of the material through the creation of quantum wells or, in emerging

two-dimensional (2D) materials, atomic layers. The change in the band structure, along with the corresponding density of states in these confined structures, affects the charge transport, thereby changing the TE properties [8]. At small confinement lengths, quantum effects play a major role in the transport of carriers [9–13], providing alternative opportunities to tune materials for better power factors [14]. Two-dimensional materials, where one of the material dimensions is confined to one or a few atomic layers, are predicted to deliver a higher power factor [15–18]. After the discovery of the extraordinary electronic and thermal properties of graphene, the focus of research has shifted to other van der Waals (vdW) 2D materials that possess bandgaps and other desirable properties, including high TE efficiency [19–21], gate-tuned power factors [22–24], and flexible structure [25]. However, identifying 2D materials with a high power factor out of over 2000 possibilities [26] can be an arduous task, both in terms of fabrication and computationally expensive atomistic simulations [18].

A complementary approach to the search for new 2D TE materials is to enhance existing 2D materials by introducing potential barriers that act as energy filters, restricting transport to carriers with kinetic energy exceeding the potential barrier and thereby boosting the Seebeck coefficient. Prior studies on 3D materials incorporated energy filtering in the form of nanocomposites [27],

\*zlatana@engin.umass.edu

modulation doping [28,29], and superlattices [30,31]. It was demonstrated to increase the Seebeck coefficient [32, 33] through energy-dependent scattering [34], which may lead to improvements in the power factor [35,36], though not all materials and configurations experience it. Improving the power factor requires careful design as gains in the Seebeck coefficient are often offset by losses in conductivity [37,38], while randomized barriers can even lead to localization [39]. A recent review summarized the long history, rich literature, and design criteria for energy filtering [40]. In our recent work [41], we demonstrated the impact of barrier shape on such spatially varying potentials in silicon nanostructures using an iterative Wigner-Rode formalism, and concluded that sharp, tall barriers with small periods result in better TE performance. A series of potential barriers, such as those caused by multiple parallel gates, has also been predicted to improve the power factor in graphene [42]. Multilayer thermionic devices composed of few-layer transition metal dichalcogenides (TMDs) [43] and hexagonal boron nitride [44] sandwiched between graphene electrodes have been proposed as a route to achieve high TE efficiency from 2D materials. While the relatively weak vdW interlayer interaction in vertically stacked 2D heterostructures helps reduce lattice thermal conductivity [45,46], their cross-plane electrical transport is also degraded.

Recent achievements in the growth of lateral (in-plane) 2D heterostructures and superlattices provide an alternative direction for TE devices [47–49]. Depending on the direction of the applied electric field relative to the potential barriers created by interfaces in the heterostructure, carriers experience either confinement or energy filtering, both of which can be beneficial to TE properties. In addition to striped heterostructures [50], lateral potential barriers can also be realized in 2D materials by periodically modulating the bandgap through one of several ways, including applying local strain [51] and wrinkling [52], varying the local alloy composition [53], or patterning the substrate to vary its dielectric screening [54]. Such lateral heterostructures created from TMDs have shown promising increases in the  $ZT$  [55], but research so far has focused primarily on the lattice thermal transport [56]. However, a unified framework to assess the extent of possible enhancement, the influence barrier shape and size on TE performance, and the anisotropy between transport in the directions parallel and perpendicular to the barriers in 2D materials is still lacking.

Here we study the anisotropic transport in 2D materials, focusing on the TMD  $\text{MoS}_2$  as a prototype. We introduce a series of potential barriers to establish the extent of possible gains in TE power factors and elucidate the conditions required for achieving them. If the direction of the field is perpendicular to the barriers (perpendicular transport), they undergo energy filtering and, depending on the features of the barriers, a combination of thermionic emission

and tunneling is possible. Conversely, when the electric field is parallel to the barriers (parallel transport), the band offsets can confine the carriers by forming potential wells. Extending our previous 3D Wigner-Rode model [57] to 2D materials, we calculate the conductivity and Seebeck coefficients in both parallel and perpendicular directions in the presence of smooth or sharp potential barriers. We study the effect of their shape, height, and smoothness on the resulting TE performance and quantify the relative enhancement due to the barriers. Our simulations show higher power factors are realized for transport parallel to the potential barriers than perpendicular transport across them. We find that parallel transport is influenced by confinement while perpendicular transport is dominated by energy filtering and can result in the reduction of the power factor, especially with sharp barriers. The rest of this article is organized as follows: a brief description of the transport model is given in Sec. II, followed by a discussion on the anisotropy in carrier transport and the resultant changes in the power factor in Sec. III. We conclude by commenting on the power factor enhancements achieved along with the relative contributions of parallel and perpendicular transport.

## II. IMPLEMENTATION OF THE TRANSPORT MODEL

Simulations of TE parameters in 2D superlattices and heterojunctions require a comprehensive treatment of electron scattering from impurities, defects, and lattice vibrations (phonons) simultaneously with the potential barriers. TE efficiency in these structures is controlled by two processes: carrier scattering, which is often treated semiclassically, and carrier interactions with the potential barriers, a quantum phenomenon. The semiclassical approach to carrier transport modeling based on the Boltzmann transport equation (BTE) captures scattering, but treats carriers as point particles, which limits its ability to capture and study the quantum effects. This limitation is particularly notable in the presence of rapid potential variations in the device, as shown schematically for our model in Fig. 1, where the electron experiences changes in the electrostatic potential within the spread of the wave packet. To address this limitation of the BTE, an additional force term, called the quantum evolution operator, based on the Wigner potential [58] is introduced here. This Wigner-Boltzmann formalism effectively captures both decoherence through electron scattering and quantum effects due to spatial potential variations, whether they come from heterostructure interfaces, band offsets, or external gates.

### A. Wigner-Boltzmann transport equation formalism

Quantum effects are incorporated into the BTE in the form of an additional force through the quantum evolution term [ $Qf_w(r, k, t)$ ] and the resultant Wigner-Boltzmann

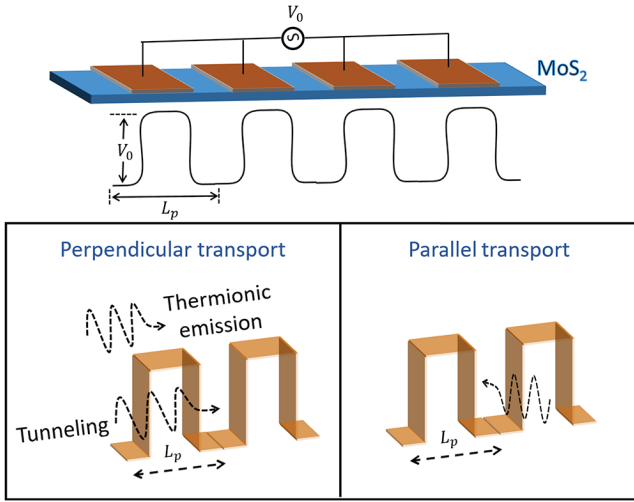


FIG. 1. Schematic of the simulated structure to study energy filtering in single-layer (SL) MoS<sub>2</sub> with a series of spatially varying potential barriers. Here the effect of potential barriers on electron transport with electrons flowing into the barriers (perpendicular transport) and flowing parallel to the potential well (parallel transport) are studied. We denote by  $L_p$  the period of the applied potential barrier.

transport equation (WBTE) can be written as

$$\left(\frac{\partial}{\partial t} + v_r \nabla_r + \frac{eF}{\hbar} \nabla_k\right) f_w(r, k, t) = Qf_w(r, k, t) + \left(\frac{\partial f_w}{\partial t}\right)_{\text{coll}}. \quad (1)$$

Here  $v_r$  is the group velocity,  $F$  is the applied electric field,  $e$  is the charge of an electron, and  $\hbar$  is the Planck constant. Any additional effects on carriers are captured in the WBTE: the applied electric field by the drift term ( $eF\nabla_k/\hbar$ ), spatial variations in doping by the diffusion term ( $v_r\nabla_r$ ), boundaries and carrier collisions by the collision operator  $[(\partial f_w/\partial t)_{\text{coll}}]$ . The Wigner formalism allows us to include quantum effects, but there are several limitations to its use in quantum device modeling. In some Wigner simulations, the use of semiclassical boundary conditions for contacts results in nonphysical results. This is due to the nonlocal nature of the Wigner equation that is incompatible with the standard boundary scheme, especially in the coherent regime that produces nonunique solutions [59,60]. This limitation is overcome in our work by focusing on periodic systems where contacts are replaced with periodic boundary conditions.

The quantum evolution term,  $Qf_w(r, k) = \int dk' V_w(r, k - k') f_w(r', k, t)$ , where

$$V_w(r, k) = \frac{1}{i\hbar(2\pi)^d} \int dr' e^{-i'k} \left[ V\left(r + \frac{r'}{2}\right) - V\left(r - \frac{r'}{2}\right) \right], \quad (2)$$

is called the Wigner potential. Here  $V(r \pm r'/2)$  represents the potential of an electron wave packet centered at  $r$  with a spread of  $r'$  due to the potential barriers introduced in the material. The quantum evolution term at equilibrium  $Qf_w(r, k)$  for any general infinite periodic series of potentials [61] with period length of  $L_p$ , depicted in Fig. 1, is

$$Qf_w(r, k) = \sum_{m=1}^{\infty} W_m(r) \left[ f_w\left(r, k - \frac{m\pi}{L_p}\right) - f_w\left(r, k + \frac{m\pi}{L_p}\right) \right], \quad (3)$$

where  $W_m(r)$  is the quantum weight determined by the shape of the potential. A cosine-shaped periodic potential can be written in the form

$$V(r) = V_0 \left[ 1 + \cos\left(\frac{2\pi}{L_p} r\right) \right] \quad (4)$$

with  $W_m(r) = A \sin(K_0 r)/(\pi \hbar)$  at  $m = 1$  in  $Qf_w(r, k)$ . A sharp, nearly square-shaped potential is represented using

$$V(r) = \frac{V_0}{2} \{-\text{erf}[\beta(r - \alpha)] + \text{erf}[\beta(r + \alpha)]\}, \quad (5)$$

and the resulting quantum weight in  $Qf_w(r, k)$  is

$$W_m(r) = \frac{2V_0}{\pi \hbar m} e^{-m^2 \pi^2 / \beta^2 L_p^2} \sin\left(\frac{2\pi m \alpha}{L_p}\right) \sin\left(\frac{2\pi m r}{L_p}\right). \quad (6)$$

Here,  $\beta$  controls the sharpness of the barrier, while  $\alpha$  is the duty cycle (ratio of barrier width to the total period length) of barriers.

## B. Iterative solver for the WBTE

To solve the WBTE, an iterative scheme based on a full-band version of Rode's method is implemented. In Rode's iterative method, the carrier distribution probability is expanded to first order using Legendre polynomials and written as a sum of the equilibrium component [determined by Fermi-Dirac statistics,  $f_o(k)$ ] and a small perturbation  $[g(k)]$  in the direction of the applied field:

$$f(k) = f_o(k) + \sum_{n=1} g_n(k) p_n[\cos(\theta)]. \quad (7)$$

Here  $\theta$  is the angle between the crystal wavevector  $k$  and the direction of transport. Furthermore, using the standard Boltzmann form of the collision operator, the perturbation to carrier distribution in the presence of potential barriers

is calculated using a self-consistent Jacobi iteration as

$$g_{i+1}(k) = \left[ I_i(k) + \frac{eF}{\hbar} \frac{\partial f_0}{\partial k} - v(k) \frac{\partial f}{\partial r} + Q_{fw}(r, k) \right] / S_o(k), \quad (8)$$

where

$$I_i(k) = \sum_{k'} \Lambda(k') g_i(k') \delta[E(k) \pm E_{ph} - E(k')]. \quad (9)$$

To calculate the integrals  $I(k)$ , we use a 2D version of the spherical averaging method [62], where the  $\delta$  function is evaluated by expanding the band structure inside a circle of radius  $R_s$  to compute the length of the constant-energy contour with a weight of  $\Lambda(k')g_i(k')$ . Here  $\Lambda$  is a scattering-dependent prefactor that helps to include the in-scattering rates and  $S_0$  is the sum of the out-scattering processes for inelastic processes [57].

A general Jacobi iteration is implemented to solve for  $g(k)$  in Eq. (8), along with successive over relaxation to achieve better convergence. The calculated perturbation  $[g(k)]$  to distribution function is used to calculate the transport distribution function (TDF) as

$$\sigma(E) = \frac{1}{\Omega(2\pi)^2 F} \int v(k) g(k) \delta[E - E(k)] d^2k, \quad (10)$$

where  $v(k)$  is the group velocity of carriers,  $\Omega$  is the volume of the first Brillouin zone, and  $F$  is the applied electric field. We can recover the widely used relaxation-time-approximation (RTA) solution of the BTE by substituting the zeroth-iteration solution of the perturbation  $g_0(k) = eFv(k)\tau(k)[\partial f_0(E)/\partial E]$ . Here,  $\tau(k)$  is the relaxation time, which is the inverse of the total out-scattering rate  $S_o(k)$  in the RTA. Once the iteration reaches convergence, as measured by the norm of the difference between successive iterations,  $S$  and  $\sigma$  are calculated from the TDF as

$$\sigma = \int \sigma(E) dE, \quad (11)$$

$$S = -\frac{1}{eT} \frac{\int \sigma(E)(E - E_f) dE}{\int \sigma(E) dE}, \quad (12)$$

where  $E_f$  is the Fermi energy level and  $T$  the temperature of the material.

### C. Electronic structure and carrier scattering

The electronic structure of MoS<sub>2</sub> used in this study is calculated from first principles using self-consistent density functional theory (DFT) calculations with the open-source software QUANTUM ESPRESSO [63]. For MoS<sub>2</sub>, we use a nonrelativistic norm-conserving pseudopotential

(NCPP) for molybdenum (Mo) and a scalar relativistic NCPP for sulfur (S). The potentials employed a Martins-Troullier method with a Perdew-Wang exchange correlation. The lattice constant of MoS<sub>2</sub> used here is  $a = 3.125$  Å and  $z = 3.11$  Å, where  $z$  is the S-S distance. Planes of atomic trilayers of MoS<sub>2</sub> are separated by a 20 Å vacuum to calculate the monolayer band structure and a cutoff energy of 140 Ry is used. A convergence threshold of  $10^{-16}$  is implemented for the initial total energy calculation on a Monkhorst-Pack grid size of  $6 \times 6 \times 4$ . Using the central difference method, the group velocities in each band  $[v(k)]$  are obtained to calculate the transport properties.

The scattering mechanisms implemented here are acoustic phonon scattering, Fröhlich interactions, and optical phonon scattering using the electron-phonon deformation potentials determined from first principles [64]. An acoustic deformation potential of 2.1 eV is used for longitudinal acoustic phonons and 5.2 eV for transverse acoustic phonons. For inelastic scattering, an optical phonon deformation potential of  $2.6 \times 10^8$  eV cm<sup>-1</sup> for longitudinal optical (LO) phonons with a phonon energy of 48 meV. A deformation potential of  $4.1 \times 10^8$  eV cm<sup>-1</sup> is used for homopolar phonons with a phonon energy of 50 meV. A coupling constant of 98 meV is used for Fröhlich (LO) interactions.

## III. RESULTS

To validate our model's ability to reproduce the intrinsic behavior, we calculate TE parameters for SL MoS<sub>2</sub> without any potential barriers. In Fig. 2(a) we show the dependence of the Seebeck coefficient (solid lines) and conductivity (dashed lines) on the carrier concentration in intrinsic MoS<sub>2</sub> at temperatures of 100, 200, 300, and 400 K. The solid lines in Fig. 2(b) show the calculated power factors corresponding to Fig. 2(a), with the maximum observed at a carrier concentration of  $7 \times 10^{12}$  cm<sup>-2</sup> at room temperature and below. Beyond this value, the power factor drops, which can be traced back to both the Seebeck coefficient and mobility [dashed lines in Fig. 2(b)] degrading at high carrier concentrations. Comparing our results with experimental measurements [65], there is good agreement in the Seebeck coefficient of intrinsic MoS<sub>2</sub>. The power factor calculated here is slightly higher than experimental measurements because we focus on phonon-limited carrier transport, resulting in higher electrical conductivity than the measurements, which likely included some scattering from charged impurities. Our simulations show a peak power factor of 23 mWm<sup>-1</sup> K<sup>-2</sup> at 300 K, whereas experimental measurements show peak power factors of 0.15 mWm<sup>-1</sup> K<sup>-2</sup> [66] and 5 mWm<sup>-1</sup> K<sup>-2</sup> [65]. In this study, we assume field-effect (electrostatic) doping by a series of gates, so carriers do not experience ionized impurity scattering from dopants, resulting in higher

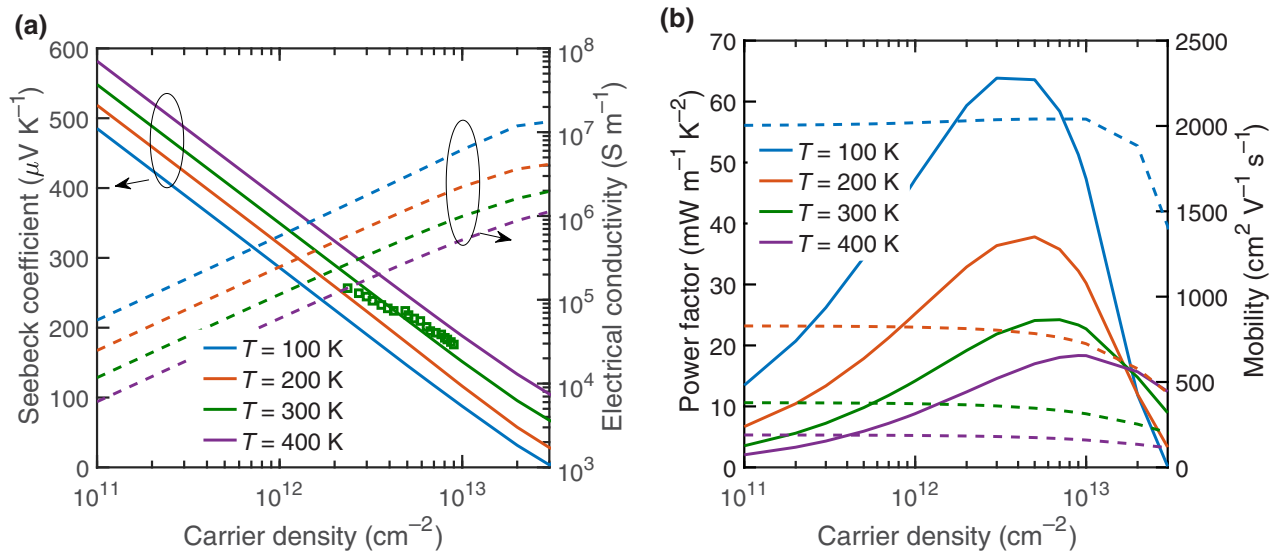


FIG. 2. TE properties of MoS<sub>2</sub> calculated by varying the carrier densities of electrons at various temperatures. The Seebeck coefficient and electrical conductivity are plotted in (a) by varying the carrier density. From (b), a peak in the power factor (solid lines, left axis) is observed at a carrier density of around  $7 \times 10^{12} \text{ cm}^{-2}$  at temperatures below 300 K, attributed to the drop in electron mobility (dashed lines, right axis).

electrical conductivity. The absence of ionized impurity scattering is observed in field-effect-doped TMD WSe<sub>2</sub> [67] in the form of higher mobility compared to Ta-doped WSe<sub>2</sub> [68]. The mobility in SL MoS<sub>2</sub> is reduced fivefold due to ionized-impurity scattering [69] when the impurity density is increased from  $10^{11}$  to  $10^{13} \text{ cm}^{-2}$ . Our phonon-limited mobility values (around  $400 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$  at room temperature), shown as dashed lines in Fig. 2(b), are in good agreement with those calculated from first principles [64].

### A. Perpendicular transport

Next, spatially varying potentials are introduced into the MoS<sub>2</sub> and TE parameters are calculated by solving the WBTE using our Wigner-Rode iterative method. Perpendicular transport is modeled after introducing both smooth and sharp barriers. In Fig. 3(a) we show the effect of the potential barrier height ( $V_0 - E_f$ ) on the TE performance for both cosine (smooth) and nearly square (sharp) barriers. With an increase in ( $V_0 - E_f$ ) and the absence of tunneling,  $S$  increases because of energy filtering from the thermionic emission of carriers that allows only high energy electrons to flow across the barrier. This can be seen in the barriers with wide period lengths,  $L_p = 7 \text{ nm}$  (irrespective of barrier shape, smooth or sharp) and in smooth barriers with short period lengths,  $L_p = 3 \text{ nm}$ . When carriers are moving perpendicular to the sharp potential barriers, tunneling emerges in narrow potential barriers and results in a reduction of  $S$  [solid green line in Fig. 3(a)], particularly with effective barrier heights ( $V_0 - E_f$ ) greater

than 16 meV. This in turn allows more carriers to cross the barrier, increasing the electrical conductivity [dashed green lines in Fig. 3(a)] compared to wide sharp potential barriers [dashed purple lines in Fig. 3(a)].

To better understand this behavior of  $S$ , energy resolved  $S(E)$  is plotted for both narrow and wide sharp barriers in Figs. 3(c) and 3(d). In thin sharp barriers, the tunneling of the carriers is higher and can be seen in the form of low average energy of the carriers participating in the transport. Wider sharp barriers are efficient at filtering the carriers and result in a larger contribution to  $S$ . Coming to the  $\sigma$ , conductivity decreases with the effective barrier height irrespective of the barrier shape and period length. The observed relative difference is due to the variation in the tunneling of carriers as discussed above. For sharp barriers with thin period lengths,  $L_p = 3 \text{ nm}$ , this results in a reducing power factor beyond 16 meV. At wide period lengths with sharp barriers, the reduction in conductivity compensates for any gains in  $S$  which results in an overall reduction in power factor. In smooth barriers, power factor increases with effective barrier height ( $V_0 - E_f$ ) and converges to 25% for thin period lengths whereas for wide barriers power factor changes almost linearly with effective barrier height.

To this point, the effective barrier height ( $V_0 - E_f$ ) was changed using  $V_0$  while keeping the Fermi level constant. To understand the influence of the carrier concentration  $N_d$  via the Fermi level ( $E_f$ ), the barrier height is changed using  $E_f$  by keeping  $V_0$  at 13 meV. The peak in the power factor with changing  $E_f$  is seen around  $N_d = 7 \times 10^{12} \text{ cm}^{-2}$  ( $E_f = -10 \text{ meV}$ ), the same as in the intrinsic monolayer

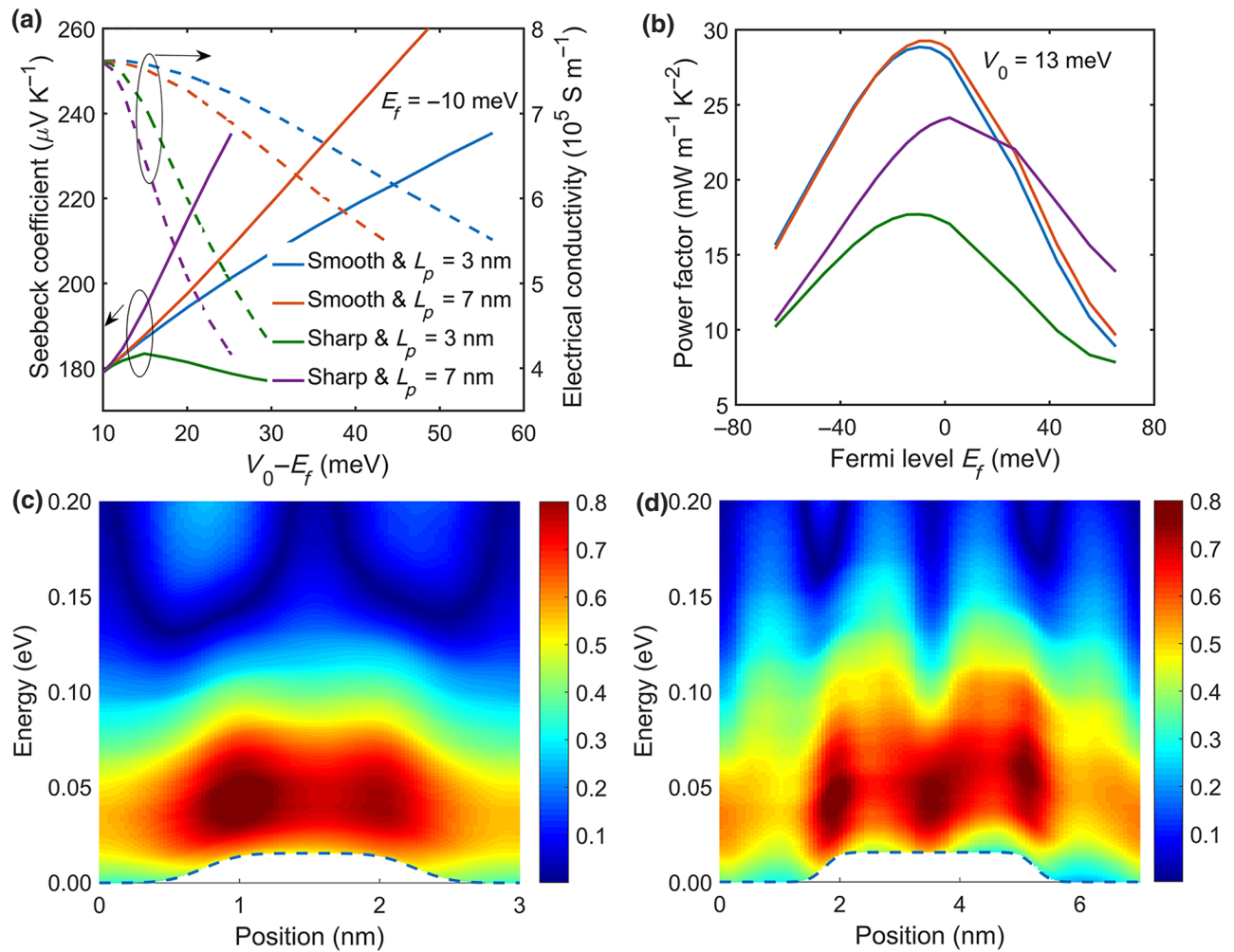


FIG. 3. Perpendicular charge transport in the presence of potential barriers at  $T = 300 \text{ K}$  in MoS<sub>2</sub>. (a) Effect of potential barrier height ( $V_0 - E_f$ ) on  $S$  and  $\sigma$  with smooth and sharp barriers at a carrier density of  $7 \times 10^{12} \text{ cm}^{-2}$ . (b) Power factor calculated by varying the Fermi level with  $V_0$  fixed at  $13 \text{ meV}$  for the same barriers as (a). The peak in the power factor still stays at  $7 \times 10^{12} \text{ cm}^{-2}$ . To understand the difference in  $S$  for sharp barriers with (c)  $L_p = 3 \text{ nm}$  and (d)  $L_p = 7 \text{ nm}$ , energy resolved  $S$  is plotted (dashed lines represent the barrier dimensions in the material). The heat map shows the higher tunneling in sharp barriers with  $L_p = 3 \text{ nm}$  that results in lower average energy for the carriers.

MoS<sub>2</sub>. Because of the increased proportion of tunneling from lower-energy carriers around the middle of the barrier height in sharp barriers, smooth barriers have higher power factors than sharp barriers in the case of perpendicular transport.

### B. Parallel transport

The perpendicular transport simulations in MoS<sub>2</sub> with potential barriers helped us illuminate the interplay between tunneling and energy filtering on the TE power factor. To compare it with the influence of carrier confinement, the direction of the electric field is changed to be parallel to the barriers. In parallel transport, our simulations show sharp barriers have higher  $S$  [as shown

in Fig. 4(a)] due to efficient carrier confinement that increases the average carrier energy. This effect is more predominant in potential barriers with thin period lengths. This confinement of carriers with the potential wells created by the barriers effects the conductivity of carriers. For smooth barriers,  $\sigma$  is higher than for sharp barriers and this behavior is not effected by the period length [also seen in Fig. 4(a)]. To understand this behavior, the energy-resolved conductivity is plotted using Eq. (10) at  $L_p = 3 \text{ nm}$  for smooth [Fig. 4(c)] and sharp [Fig. 4(d)] barriers. The relatively low barrier height of  $0.0155 \text{ eV}$  compared to the average energy of carriers ( $1 k_B T = 0.0259 \text{ eV}$ ) allows for significant conduction of carriers above the potential barrier. The energy used in Figs. 4(c) and 4(d) is relative to the band edge, which follows the potential barriers.

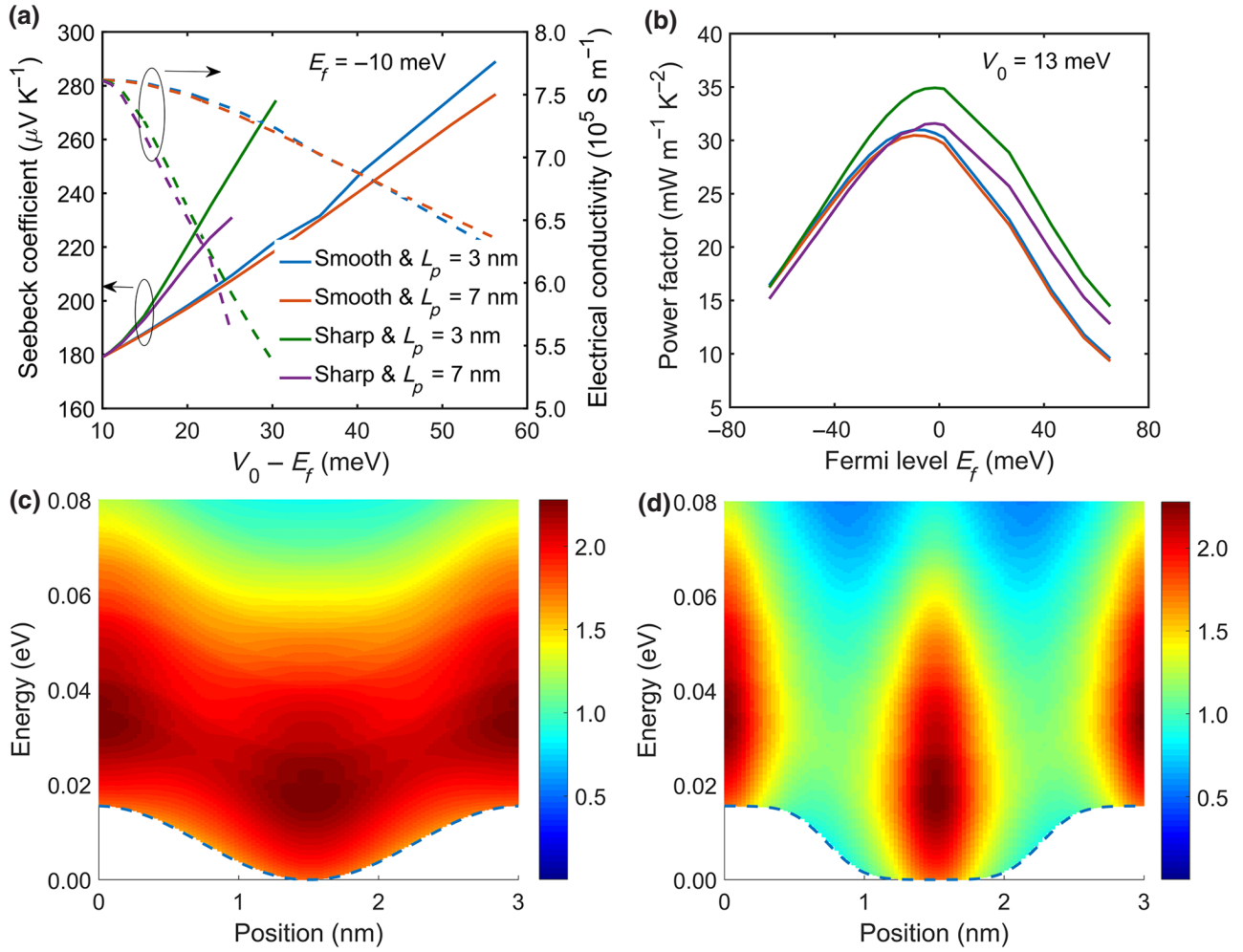


FIG. 4. Parallel charge transport in the presence of potential barriers at  $T = 300$  K in MoS<sub>2</sub>. (a) Effect of potential barrier amplitude ( $V_0 - E_f$ ) on  $S$  and  $\sigma$  with smooth and sharp barriers at a carrier density of  $7 \times 10^{12}$  cm<sup>-2</sup>. (b) Power factor calculated by varying the Fermi level with the barrier height fixed at 13 meV for the same barriers as (a). The peak in the power factor is observed at  $V_0 - E_f = 23$  meV  $= 0.9 k_B T$  and the calculated carrier density at the peak where  $E_f = -10$  meV is  $7 \times 10^{12}$  cm<sup>-2</sup>. To understand the difference in  $\sigma$  for (c) smooth and (d) sharp barriers, energy resolved  $\sigma$  [Eq. (10)] is plotted (dashed lines represent the barrier dimensions in the material). Lower  $\sigma$  seen in sharp barriers is a result of the effective confinement experienced by carriers, as shown in the heat map.

Sharp barriers confine carriers more effectively compared to the smooth barrier, which can be seen in the lack of conducting channels in the presence of sharp barriers. Even though this explains the lower conductivity in sharp barriers, the higher Seebeck coefficient translates to a higher power factor in sharp barriers.

Similar to the perpendicular transport,  $E_f$  is changed independent of  $V_0$  that is kept constant at 13 meV. The power factor calculated for smooth and sharp barriers at different period lengths shows a peak at  $N_d = 7 \times 10^{12}$  cm<sup>-2</sup> ( $E_f = -10$  meV), which is consistent with perpendicular transport. Also, sharp barriers outperform smooth barriers in terms of the power factor and barriers with thin period lengths are more effective in confining carriers, resulting in a higher power factor.

#### IV. ANISOTROPY IN THE TE POWER FACTOR

To understand the anisotropy in TE properties, the power factor is calculated using the perpendicular and parallel transport simulations for smooth [Fig. 5(a)] and sharp barriers [Fig. 5(b)]. Parallel transport dominated by carrier confinement always results in a higher power factor, which doubles from  $25$  mWm<sup>-1</sup> K<sup>-2</sup> without barriers to over  $50$  mWm<sup>-1</sup> K<sup>-2</sup>, a record-high value exceeding those reported for graphene encased in hexagonal boron nitride [70]. The significant increase in  $S$  compared to the reduction in  $\sigma$  with the barrier height coupled with the quadratic dependency of  $S$  on the power factor results in power factor enhancement observed in parallel transport. The increase in the power factor in parallel transport by increasing the barrier height ( $V_0 - E_f$ ) will eventually converge to the

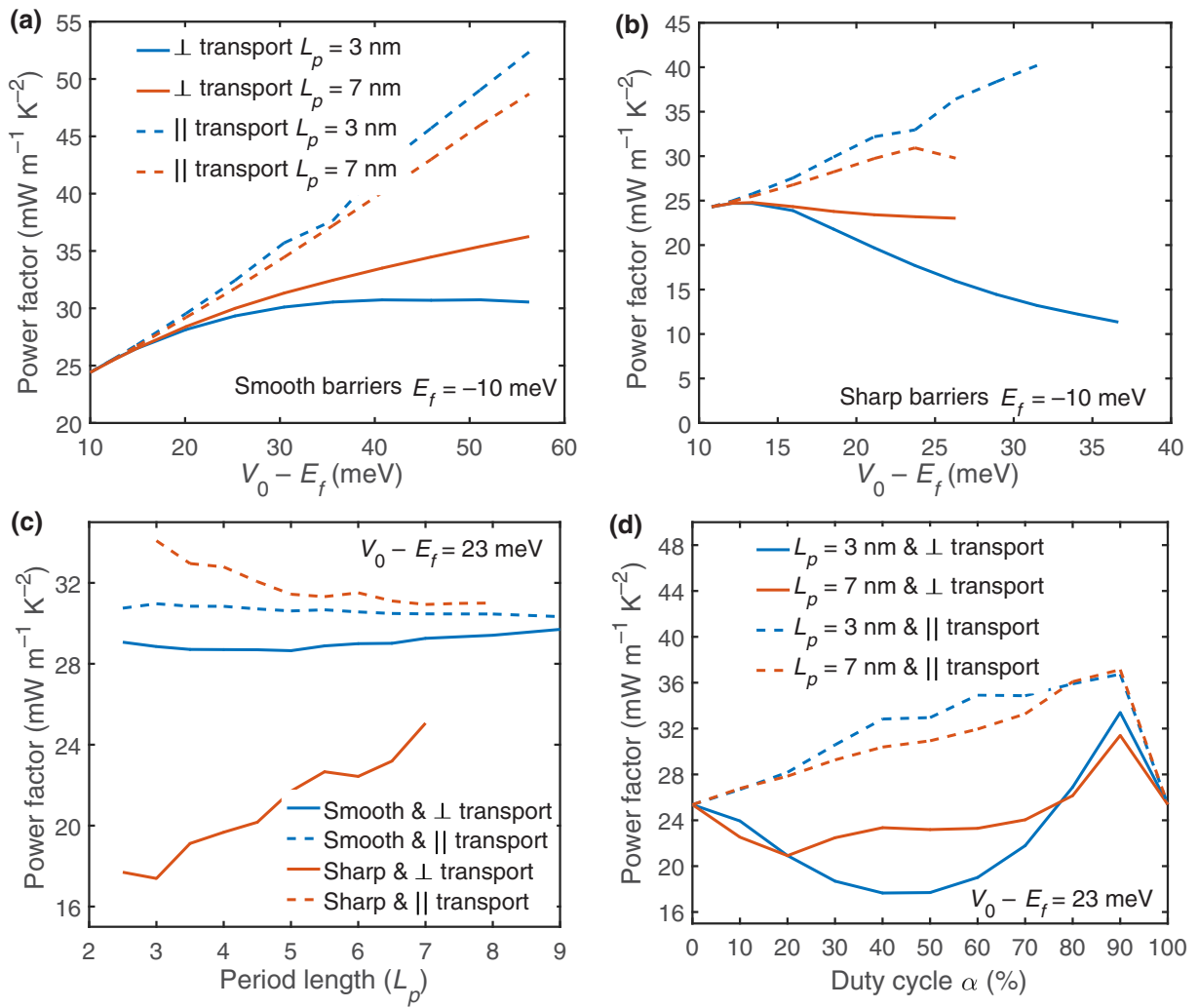


FIG. 5. Changes in the power factor of SL MoS<sub>2</sub> by introducing potential barriers using a series of gates. Comparison between perpendicular and parallel transport in (a) smooth barriers and (b) sharp barriers at different period lengths. (c) Effect of period length on the power factor in smooth and sharp barriers in both the transport regimes. (d) Power factor changes with the asymmetry in the shape of the sharp barrier are observed by changing  $\alpha$ .

power factor of an infinite potential well. In the perpendicular transport regime, the smooth barriers outperform the sharp barriers, while sharp barriers are better for parallel transport. A 25% increase in the power factor can be achieved using tall smooth barriers under perpendicular transport. But tunneling in sharp barriers at thin period lengths and low conductivity of carriers at wide period lengths reduce the power factor, even below the intrinsic values. The power factor enhancement varies linearly [Fig. 5(a)] with effective barrier height once transport is moved in parallel with the barriers. In smooth barriers, enhancement of the power factor in parallel transport is 70% higher than perpendicular transport with tall barriers. This difference reaches around 300% for sharp barriers when comparing both transport regimes at low period lengths.

The difference in transport mechanisms of parallel and perpendicular transport can be seen in their respective dependence on the period lengths ( $L_p$ ). In Fig. 5(c) we show the power factor calculated at different period lengths with an effective barrier height of 23 meV for both sharp and smooth barriers. In the presence of sharp barriers where tunneling and confinement are strong, increasing  $L_p$  improves the power factor in perpendicular transport and decreases it in parallel transport. In perpendicular transport, where energy filtering and tunneling impact transport, increasing  $L_p$  improves energy filtering (through thermionic emission) and reduces tunneling, resulting in an increase in the power factor. Confinement of carriers in parallel transport reduces the power factor with increases in  $L_p$ . This is a consequence of the higher energies of the available states that participate in transport when carriers



travel through the potential wells with a thin period length. These higher energies translate to higher  $S$  for thin period lengths, as seen in Fig. 4(a), even though  $\sigma$  experiences no effect. Varying  $L_p$  for smooth barriers shows no change in the power factor at a given barrier height.

Another sharp barrier parameter that can affect the TE performance is the duty cycle (ratio of the barrier width to the period length) of the potential barrier. To this point, all the simulations are performed by assuming a symmetric sharp potential barrier ( $\alpha = 50\%$ ). By changing the duty cycle of sharp barriers, the power factor of the structure is plotted in Fig. 5(d). In perpendicular transport, the power factor increases in sharp barriers that are asymmetric ( $\alpha$  higher or lower than 0.5), especially barriers with lower period lengths ( $L_p = 3$  nm). At higher period lengths, increasing  $\alpha$  improves the power factor of the structure due to more efficient energy filtering with the wide barrier. As the duty cycle  $\alpha$  approaches 100%, the wells in the potential barriers disappear, creating a constant potential throughout the material. This results in an intrinsic material with a higher band edge that results in the difference in the power factor and does not converge to the value at  $\alpha = 0\%$ . In parallel transport, the asymmetry in barriers results in changing the effective potential well width. Reducing the well width raises the energy levels in the well, thus altering the resulting power factor. Hence, highly asymmetric barriers (having larger  $\alpha$ ) result in thin potential wells that produce higher power factors.

## V. CONCLUSION

Improving thermoelectric efficiency of nanoscale TE devices requires a thorough understanding of carrier scattering, tunneling, and confinement. Any 2D material with spatially varying lateral potential barriers experiences these effects, depending on the direction of the electric field with respect to the potential barrier direction. When the field is perpendicular to the potential barriers, carrier transport is affected by thermionic emission and tunneling, while in the direction parallel to the barriers, carriers are confined by the change in the potential across the material. We implemented a comprehensive model based on the Wigner formalism and the Boltzmann transport equation to fully account for the influence of the potential barriers at the nanoscale along with the scattering of carriers. Using electronic structure obtained from first-principle DFT calculations, we calculated TE properties of MoS<sub>2</sub> with lateral potential barriers and varied the shape and size of the barrier. Our results show that potential barriers result in a twofold enhancement of the power factor, from 25 to 50 mWm<sup>-1</sup> K<sup>-2</sup>, particularly with parallel transport in sharp barriers having small widths. Regardless of the barrier shape, carrier transport parallel to the barriers results in a factor of three enhancement in the power factor compared to perpendicular transport. We observe significant

anisotropy as smooth barriers outperform sharp barriers in the case of perpendicular transport, while sharp barriers have a higher power factor with parallel transport. Lastly, our simulations show that introducing potential barriers does not always improve the power factor, particularly when transport is perpendicular to the barriers, nor that sharp barriers are universally advantageous. Our study will guide future implementations of flexible and efficient 2D TE devices with significantly enhanced power factors.

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